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# Addition of Amines and Hydroborane to the Disilyne RSi $\equiv$ SiR (R = Si<sup>/</sup>Pr[CH(SiMe<sub>3</sub>)<sub>2</sub>]<sub>2</sub>) Giving Amino- and Boryl-Substituted Disilenes

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Since the isolation of the first stable tetramesityldisilene Mes<sub>2</sub>Si=SiMes<sub>2</sub> (Mes = 2,4,6-trimethylphenyl) in 1981,<sup>1</sup> numerous disilene derivatives containing a silicon-silicon double bond have been isolated and characterized.<sup>2</sup> There are several methods for the synthesis of stable disilenes:<sup>2</sup> dimerization of silylenes, photochemical cleavage of cyclotrisilanes, reductive coupling of dihalosilanes, and the reaction of dilithiosilanes with dihalosilanes, giving disilenes of the types A<sub>2</sub>Si=SiA<sub>2</sub> or A<sub>2</sub>Si=SiB<sub>2</sub>. The reaction of disilenides with aryl halides leads to the formation of the type A<sub>2</sub>Si=SiAB (B = aryl group).<sup>3</sup> The reduction of L:SiCl<sub>4</sub> (L = 1,3-bis(2,6-diisopropylphenyl)imidazol-2-ylidene) to afford a new type of a disilene, L:Si=Si:L, was also recently reported.<sup>4</sup> However, methods for the synthesis of heteroatom-substituted disilenes are currently very limited.<sup>5</sup>

Recently, heavier group 14 alkyne analogues have been synthesized and isolated.<sup>6-9</sup> Among them, the silicon-silicon triply bonded compounds, disilynes, have been prepared by our and Wiberg's groups<sup>7,8</sup> using bulky silyl groups, and we reported a full characterization of the first isolable crystalline disilyne 1, RSi=SiR (R = Si<sup>i</sup>Pr[CH(SiMe<sub>3</sub>)<sub>2</sub>]<sub>2</sub>), with a *trans*-bent structure. Tokitoh's group also recently reported a disilyne derivative with bulky aryl groups.<sup>9</sup> The disilyne **1** is very reactive toward alkenes,<sup>10</sup> alkynes,<sup>10</sup> (BuLi,<sup>11</sup> alkali metals,<sup>11b</sup> nitriles,<sup>12</sup> and silylcyanides<sup>13</sup> to give a disilenyllithium, 1,2disilacyclobutenes, 1,2-disilabenzene derivatives, triaza-1,4-disilabicyclo[2.2.2]oct-2,5,7-triene derivatives, disilyne-silylisocyanide adduct, and 1,4-diaza-2,3-disilabenzene derivatives, respectively. We report here a new highly effective route for the synthesis of a type of heteroatom-substituted disilenes R(R'<sub>2</sub>E)Si=SiHR 2a, 2b, and 3 (R'<sub>2</sub>E = Et<sub>2</sub>N (**2a**), Ph<sub>2</sub>N (**2b**), and 9-borabicyclo[3.3.1]nonan-9-yl (**3**)) by the reaction of disilyne 1 with diethylamine, diphenylamine, or 9-borabicyclo[3.3.1]nonane (9-BBN), respectively.<sup>5</sup> We also discuss the  $\pi$ -conjugation between the Si=Si double bond and the lone pair on the nitrogen atom or the vacant 2p orbital on the boron atom, correlated with the dihedral angle between the Si=Si double bond and the plane of the amino or boryl group.<sup>5</sup>

The reaction of disilyne 1 with an excess amount of diethylamine in toluene from -78 °C to room temperature gave an orange solution, from which amino-substituted disilene 2a was isolated as orange crystals in 78% yield (Scheme 1).<sup>14</sup> The reaction of **1** with diphenylamine in C<sub>6</sub>D<sub>6</sub> also afforded amino-substituted disilene **2b**; however, the reaction was very slow and it took 1 month for the completion because of steric hindrance. Neither 2a nor 2b reacted with excess amine, in contrast to the reaction of 1 with alcohols, which only gave the 1:2 adduct dialkoxydisilane.<sup>15</sup> The molecular structures of 2a and 2b were determined by X-ray crystallography, their crystal structures are shown in Figure 1 (2a: left; 2b: right).<sup>14</sup> The sums of the bond angles around the nitrogen atoms are nearly 360° in both 2a and 2b, which is common among monosilyl-substituted amines.<sup>16</sup> However, the orientation of the amino substituents is dramatically different in 2a and 2b. The Si=Si double bond plane and amino group plane of 2a are almost parallel to each other with the torsion angle Si2-Si1-N1-C1



of ca. 7°, which allows conjugation between the Si=Si double bond and the lone pair on the nitrogen atom. On the other hand, in **2b**, the orientation of the amino substituent to the Si=Si double bond plane is close to perpendicular with the torsion angle Si2-Si1-N1-C1 of ca. 67°, because of the two bulky phenyl groups. Thus, **2b** has almost no  $\pi$ -conjugation between the Si=Si double bond and the amino group. The shorter Si1-N1 bond length of **2a** (1.717(2) Å) compared with that of **2b** (1.775(9) Å) also reflects the presence or absence of  $\pi$ -conjugation. The Si=Si double bond length of **2b** (2.1790(14) Å) is slightly longer than that of **2a** (2.1647(2) Å), but this can be explained by assuming that the effect of steric hindrance of the bulky diphenylamino group is larger than the  $\pi$ -conjugation effect.



**Figure 1.** ORTEP drawing of **2a** (left) (30% thermal ellipsoids). Hydrogen atoms except for H2 on Si2 are omitted for clarity. Selected bond lengths (Å): Si1–Si2 = 2.1647(10), Si1–Si3 = 2.3966(9), Si1–N1 = 1.717(2), Si2–Si8 = 2.3550(10), Si2–H2 = 1.45(4). Selected bond angles (deg): Si2–Si1–Si3 = 116.14(4),Si2–Si1–N1 = 122.41(8),Si3–Si1–N1 = 120.10(8), Si1–Si2–Si8 = 141.72(4),Si1–Si2–H2 = 104.8(17),Si8–Si2–H2 = 108.4(17), Si1–N1–C1 = 123.46(17),Si1–N1–C3 = 120.72(18),C1–N1–C3 = 115.8(2). ORTEP drawing of **2b** (right) (30% thermal ellipsoids). Hydrogen atoms are omitted for clarity. Selected bond lengths (Å): Si1–Si2 = 2.1790(14), Si1–Si3 = 2.4320(14), Si1–N1 = 1.775(3), Si2–Si8 = 2.3723(15). Selected bond angles (deg): Si2–Si1–Si3 = 122.60(6), Si2–Si1–N1 = 116.92(12), Si3–Si1–N1 = 118.31(12),Si1–Si2–Si8 = 143.36(6),Si1–N1–C1 = 121.0(3), Si1–N1–C7 = 122.0(2), C1–N1–C7 = 116.5(3).

The NMR spectra of **2a** and **2b** also showed the presence or absence of  $\pi$ -conjugation between the Si=Si double bond and the amino group. Thus, the <sup>29</sup>Si NMR spectrum of **2a** showed characteristic signals of low-coordinate silicon atoms at 170.5 (N-*Si*=Si) and -39.3 ppm (H-*Si*=Si); the latter is greatly upfield shifted relative to those of the disilenes reported so far (63.3–154.5 ppm).<sup>2a</sup> On the other hand, the <sup>29</sup>Si NMR spectrum of **2b** showed resonance signals at 136.4 (N-*Si*=Si) and 66.6 ppm (H-*Si* = Si), both of which lie in the range of typical unsymmetrical disilenes.<sup>17</sup> The <sup>1</sup>H NMR spectrum of **2a** also showed the characteristic signal

of Si-H at 2.97 ppm, which is high-field shifted compared with that of **2b** (4.54 ppm). The contribution of zwitterionic structure **B**, which has anionic character on the H-substituted Si atom. accounts for the significantly high-field shifts of the Si-H unit of 2a compared with that of 2b (Chart 1).

## Chart 1



Although the boryl-substituted disilene is also expected to have  $\pi$ -conjugation between the Si=Si double bond and the vacant 2p orbital on the boron atom, the first boryl-substituted disilenes  $(^{t}Bu_{2}MeSi)_{2}Si=Si(SiMe^{t}Bu_{2})(BR^{*}_{2})$  4a, b  $(R^{*}_{2} = pinacol$  (4a), catechol (4b)), which we reported recently, have no  $\pi$ -conjugation because of the almost perpendicular orientation of the boryl substituent to the Si=Si double bond plane.5e However, we were able to synthesize a boryl-substituted disilene with  $\pi$ -conjugation by the reaction of 1 with hydroborane.

### Scheme 2



The reaction of 1 with 1 equiv of 9-BBN in dry THF at room temperature afforded boryl-substituted disilene 3, which was isolated as orange crystals in 53% yield (Scheme 2).14 The molecular structure of 3 determined by X-ray crystallography is shown in Figure 2.14 The dihedral angle between the boryl substituent plane and the Si=Si double bond plane is ca. 11°. The Si1-B1 bond length of **3** (2.002(4) Å) is shorter than that of **4b** (2.022(8) Å).<sup>5e</sup> The Si=Si double bond length is 2.1838(12) Å, which lies in the range of typical Si=Si double bonds (2.138-2.289 Å).<sup>2a</sup> These structural data suggest the presence of  $\pi$ -conjugation between the Si=Si double bond and the vacant 2p orbital on the boron atom.

In the <sup>29</sup>Si NMR spectrum of 3, the signals of low-coordinate silicon atoms are observed at 121.7 (B-Si=Si) and 150.5 ppm (H-Si=Si); the latter <sup>29</sup>Si NMR signal is appreciably shifted downfield compared with that of 2a (-39.3 ppm). The <sup>1</sup>H NMR spectrum of 3 also shows the characteristic signal of the Si-H unit at 6.21 ppm. The significantly downfield-shifted resonance of the Si-H unit (both <sup>29</sup>Si NMR and <sup>1</sup>H NMR), relative to those of 2a and 2b, can be reasonably explained in terms of the contribution



Figure 2. ORTEP drawing of 3 (30% thermal ellipsoids). Hydrogen atoms except for H2 on Si2 and the toluene molecule as a crystallization solvent are omitted for clarity. Selected bond lengths (Å): Si1-Si2 = 2.1838(12), Si1-Si3 = 2.3872(11), Si1-B1 = 2.002(4), Si2-Si8 = 2.3733(11), Si2-H2 = 1.42(3). Selected bond angles (deg): Si2-Si1-Si3 = 111.08(4), Si2-Si1-B1 = 116.89(11), Si3-Si1-B1 = 131.94(11), Si1-Si2-Si8 = 145.86(5), Si1-Si2-H2 = 111.2(13), Si8-Si2-H2 = 102.6(13), Si1-B1-C35 = 126.9(2), Si1-B1-C39 = 121.7(2), C35 - B1 - C39 = 111.1(3).

of zwitterionic structure **D**, which has a cationic character on the H-substituted Si atom (Chart 2).

Chart 2



The push-pull phenomenon, discussed in the disilenes 2a and 3, is well-known in olefin chemistry (enamines<sup>18a</sup> and vinylboranes<sup>18b</sup>). This influences the energy levels of the HOMO and LUMO of 2a and 3, affecting the UV-vis absorptions ( $\pi$ - $\pi$ \* transitions) of the Si=Si double bond (438 nm for 2a: 469 nm for 3; for the computational results on the model compounds 2a' and 3', see Supporting Information).

Supporting Information Available: The experimental procedure of 2a, 2b, and 3; computational results on the model compounds 2a' and 3'; tables of crystallographic data including atomic positional and thermal parameters for 2a, 2b, and 3 (PDF/CIF). This material is available free of charge via the Internet at http://pubs.acs.org.

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